

BENEQ R2

The Beneq R2 is our most affordable premium research reactor with sticker price of 130,000 EUR. This tool is compact, scalable and ergonomically designed to be the perfect way to start your ALD journey.



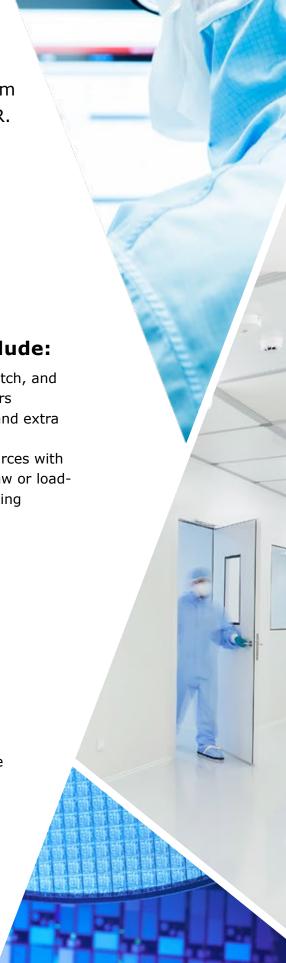
Options include:

- Single wafer, batch, and plasma chambers
- Ozone cabinet and extra gas lines
- Set of 2 hot sources with either vapor draw or loadand-release dosing

VALUE: Beneq R2 has all the components of a premium ALD reactor packed into an affordable and approachable tool. With upscale features like a dual chamber design, R2 provides the best value for an ALD starterpack.

SIMPLICITY: The R2 is standardized to provide users with a straightforward and pragmatic tool ready to be used out of the box. All main components and electrical box are included in the tool frame, giving it a small, unassuming footprint.

UPGRADABLE: The modular design of the R2 allows for quick upgrades and easy maintenance, including a 3D chamber and plasma options, for when your ALD needs change.





BENEQ R2 Specifications

PROCESS TYPE	Thermal ALD Plasma-Enhanced ALD
USAGE	Research & Development
INTEGRATION	Stand-alone
DIMENSIONS	1200mm × 600mm × 1630mm
TEMPERATURE RANGE	25-400 °C
SUBSTRATE TYPE	Up to 300 mm wafers 3D parts up to 300×420 mm



Beneq maintains the largest install base of ALD research equipment for academic research and corporate R&D. We are dedicated to providing customers with premium, versatile research equipment to meet demanding lab environments and enable cutting-edge results.



Beneq TFS200

The most flexible and highly customizable ALD research platform.



Beneq TFS500

Diverse configurations available for single and batch processes.



Beneq R2

Compact, scalable, and affordable to start your ALD journey.

